

Accepted Manuscript

Effect of substrate temperature on growth and electrical properties of pulsed laser deposition grown $0.5\text{Pb}(\text{Ni}_{1/3}\text{Nb}_{2/3})\text{O}_3$ - 0.35PbTiO_3 - 0.15PbZrO_3 thin films

Samba Siva Vadla, Ramesh Ade, Ajit R. Kulkarni, N. Venkataramani



PII: S0040-6090(18)30462-0
DOI: doi:[10.1016/j.tsf.2018.07.007](https://doi.org/10.1016/j.tsf.2018.07.007)
Reference: TSF 36764
To appear in: *Thin Solid Films*
Received date: 13 March 2018
Revised date: 29 June 2018
Accepted date: 6 July 2018

Please cite this article as: Samba Siva Vadla, Ramesh Ade, Ajit R. Kulkarni, N. Venkataramani, Effect of substrate temperature on growth and electrical properties of pulsed laser deposition grown $0.5\text{Pb}(\text{Ni}_{1/3}\text{Nb}_{2/3})\text{O}_3$ - 0.35PbTiO_3 - 0.15PbZrO_3 thin films. *Tsf* (2018), doi:[10.1016/j.tsf.2018.07.007](https://doi.org/10.1016/j.tsf.2018.07.007)

This is a PDF file of an unedited manuscript that has been accepted for publication. As a service to our customers we are providing this early version of the manuscript. The manuscript will undergo copyediting, typesetting, and review of the resulting proof before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers that apply to the journal pertain.

Effect of substrate temperature on growth and electrical properties of pulsed laser deposition grown $0.5\text{Pb}(\text{Ni}_{1/3}\text{Nb}_{2/3})\text{O}_3$ - 0.35PbTiO_3 - 0.15PbZrO_3 thin films

Samba Siva Vadla, Ramesh Ade, Ajit R. Kulkarni and N. Venkataramani *

*Department of Metallurgical Engineering and Materials Science, Indian Institute of Technology Bombay,
Mumbai-400 076, Maharashtra, India*

**Author for correspondence: ramani@iitb.ac.in*

Download English Version:

<https://daneshyari.com/en/article/8032498>

Download Persian Version:

<https://daneshyari.com/article/8032498>

[Daneshyari.com](https://daneshyari.com)